

## DMX Series Nd:YLF UV Nanosecond Lasers

[www.photonix.com](http://www.photonix.com)

Photonic Industries' DMX Series Nd:YLF UV nanosecond lasers combine remarkably high pulse energies (up to 40 mJ) within a simple, rugged, and efficient form factor. Dual Head configurations can go up to 80 mJ of pulse energy. The laser design ideally fulfills the needs of both research and industry, from pumping, to providing the necessary high energy for laser thermal processing or annealing applications in an industrial, compact form factor.



### Applications

- High pulse energy cutting, drilling, welding, marking, patterning
- Laser Life-Off (LLO) Systems, Debonding, Separation of Thin-film Semiconductor Materials
- Laser Thermal Processing (LTP)  
Annealing, Laser Heat-tempering Metal Marking, Laser Discoloration & Bleaching Plastic Marking
- Semiconductor Lithography Systems/Photolithography

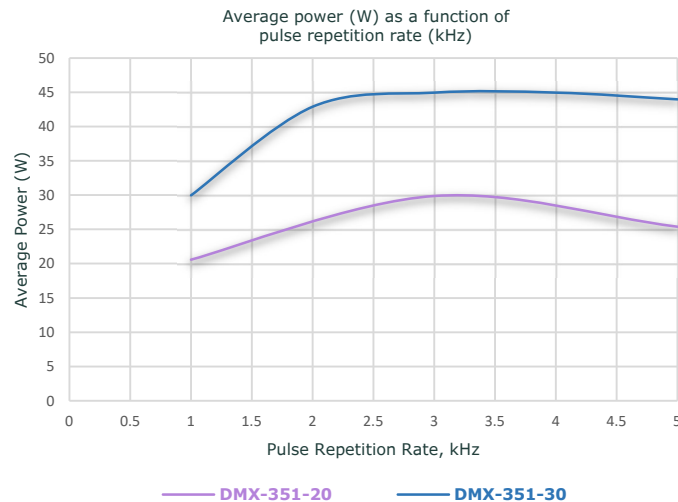
### Features

- Exceptional high pulse energy UV laser:  
Up to 40 mJ, Nd:YLF
- Two fully independent lasers, integrated into a Dual Head configuration available. Contact us.  
Up to 80 mJ, UV Nd:YLF
- Exceptional repetition rate control:  
Single shot up to 5 kHz

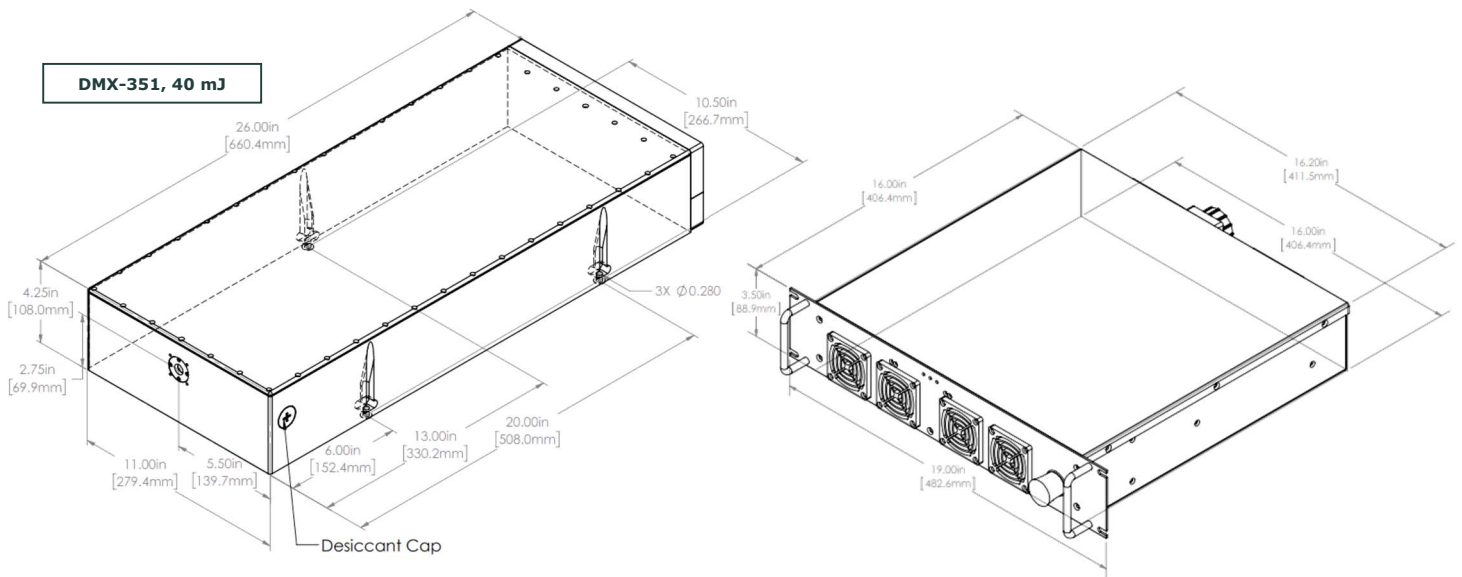
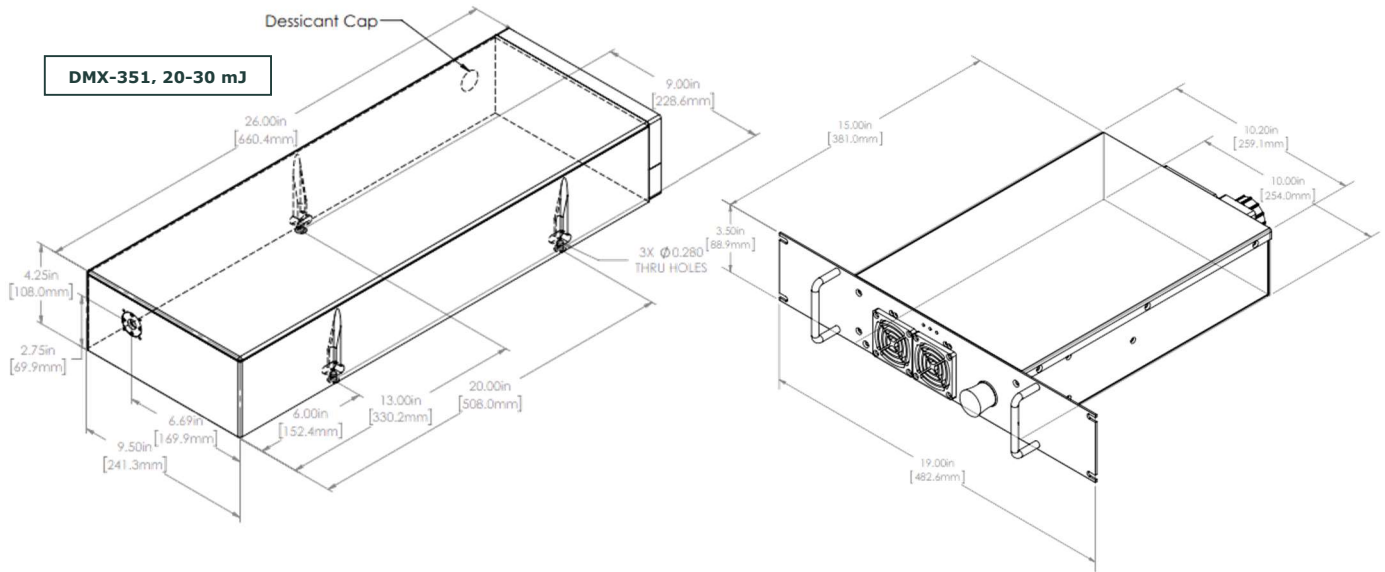
## Specifications – DMX Series High Pulse Energy Nanosecond Lasers, Nd:YLF UV Models

UV Models	DMX-351-20		DMX-351-30	DMX-351-40
Beam and output specifications				
Wavelength	351 nm			
Average power <sup>1</sup>	30 W at 3 kHz		45 W at 3 kHz	80 W at 2 kHz
Pulse energy	20 mJ at 1 kHz		30 mJ at 1 kHz	40 mJ at 2 kHz
Pulse width	~100 ns at 1 kHz			
Pulse repetition rate <sup>2</sup>	Single shot to 5 kHz			2 to 5 kHz
Pulse-to-pulse stability <sup>3</sup>	< 1.2% rms			
Long term power stability <sup>4</sup>	< 0.5% rms			
Beam spatial mode <sup>5</sup>	Multimode, M <sup>2</sup> 10 to 14			
Beam pointing stability	< 25 μrad			
Beam divergence	< 8 mrad			
Beam roundness	> 85%			
Beam diameter, at exit	~3 mm, nominal			
Polarization ratio	Horizontal; 100:1			
Operational specifications and system characteristics				
Interface	RS232, Ethernet, Software GUI, External TTL Triggering			
Warm-up time	< 5 minutes from standby, or cold start			
Electrical requirement	100-240 V AC			200-240 V AC
Line frequency	50-60 Hz			
Ambient temperature	Ambient 15°C to 30°C (59°F to 86°F) Operating Range, Relative Humidity 90% Max., non-condensing			
Power consumption <sup>6</sup>	0.8 kW		1 kW	1.75 kW
Laser head Dimensions (LxWxH)	26 x 9.5 x 4.25 in			26 x 11 x 4.25 in
Power supply Dimensions (LxWxH) <sup>7</sup>	15 x 10.2 x 3.5 in			16 x 16.2 x 3.5 in
Cooling system	Water-cooled			

1. Higher average powers available in a Dual Head configuration. Contact us.
2. Lower pulse repetition rates (down to < 1 kHz) performance achieved by pulse energy capping
3. Measured at ambient temperature  $\pm 2^\circ\text{C}$
4. Measured over 8 hours  $\pm 1^\circ\text{C}$
5. TEM<sub>00</sub> beam option available. Contact us.
6. Power consumption data does not include an external chiller's power consumption
7. Total width with rack mount option is 19 in. Please note height in rack units is 2U.



## Dimensional Drawings



Photonics Industries DMX Series nanosecond lasers have a separate external power supply box, no longer requiring an external controller or utility module. The RF driver is located in the laser head, and all control electronics and connections for operation and control of the laser can be found on the back panel of the compact laser head.

Product specifications, characteristics, and dimensional drawings are subject to change without notice.

Photonics Industries conforms to provisions of US 21 CFR 1040.10 & 1040.11 and is made under one or more US patents listed below: 9,531,147, 8,817,831, 7,869,471, 7,346,092, 7,082,149, 7,079,557, 6,999,483, 6,980,574, 6,961,355, 6,842,293, 6,762,405, 6,690,692, 6,587,487, 6,584,134, 6,366,596, 6,356,578, 6,327,281, 6,246,707, 6,229,829, 6,108,356, 6,061,370, 6,028,620, 5,936,983, 5,898,717 and Pending Patents

Copyright © 2022 by Photonics Industries International, Inc.

Main Headquarters: 1800 Ocean Ave, Ronkonkoma, New York 11779, United States

Photonics Industries International is the pioneer of intracavity harmonic lasers and is at the forefront of developing, manufacturing and marketing a wide range of nanosecond, sub-nanosecond, picosecond and femtosecond lasers for industrial, scientific, defense, and medical industries. Check out our products and see how we can help you apply our lasers to your needs.

[Website](#) - [Products](#) - [Applications](#) - [Company](#) - [Contact](#) - [International Network](#)

